



US00D962360S

(12) **United States Design Patent** (10) **Patent No.:** **US D962,360 S**
Li (45) **Date of Patent:** **** Aug. 30, 2022**

(54) **MASK**
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(72) Inventor: **Hongliang Li**, Shenzhen (CN)
(**) Term: **15 Years**
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(51) **LOC (13) Cl.** **21-01**
(52) **U.S. Cl.**
USPC **D21/660**
(58) **Field of Classification Search**
USPC D21/622, 632, 658, 659, 660, 661;
D2/741; D24/110.1; D29/108
CPC A63H 3/365; A41G 7/00; A41G 7/02
See application file for complete search history.

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(57) **CLAIM**
The ornamental design for a mask, as shown and described.

DESCRIPTION

FIG. 1 is a perspective view of a mask, showing my new design;
FIG. 2 is a front view thereof;
FIG. 3 is a rear view thereof;
FIG. 4 is a left side view thereof;
FIG. 5 is a right side view thereof;
FIG. 6 is a top plan view thereof; and,
FIG. 7 is a bottom plan view thereof.
The claimed design includes the Venom character, which is registered trademark of Marvel Characters INC.

1 Claim, 7 Drawing Sheets



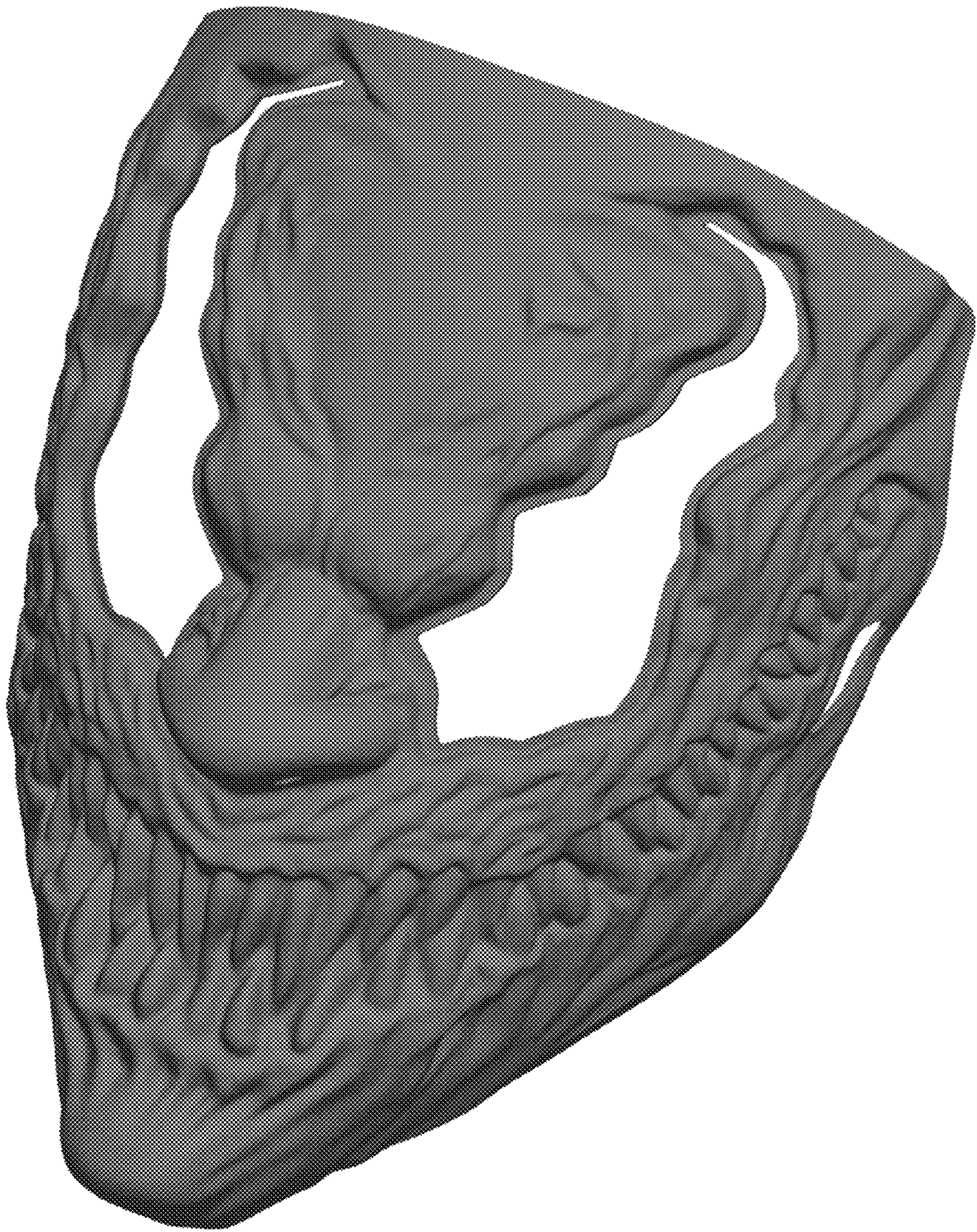


FIG. 1



FIG. 2



FIG. 3

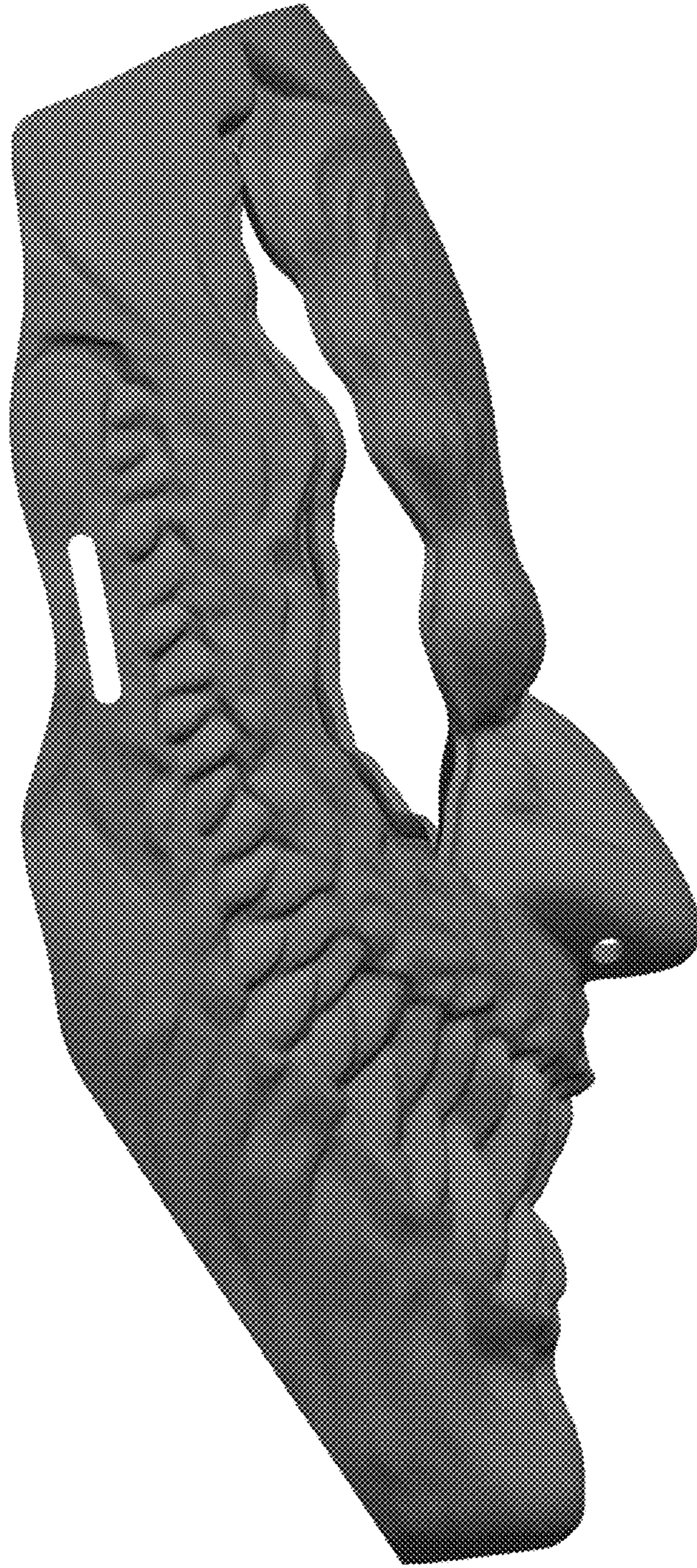


FIG. 4

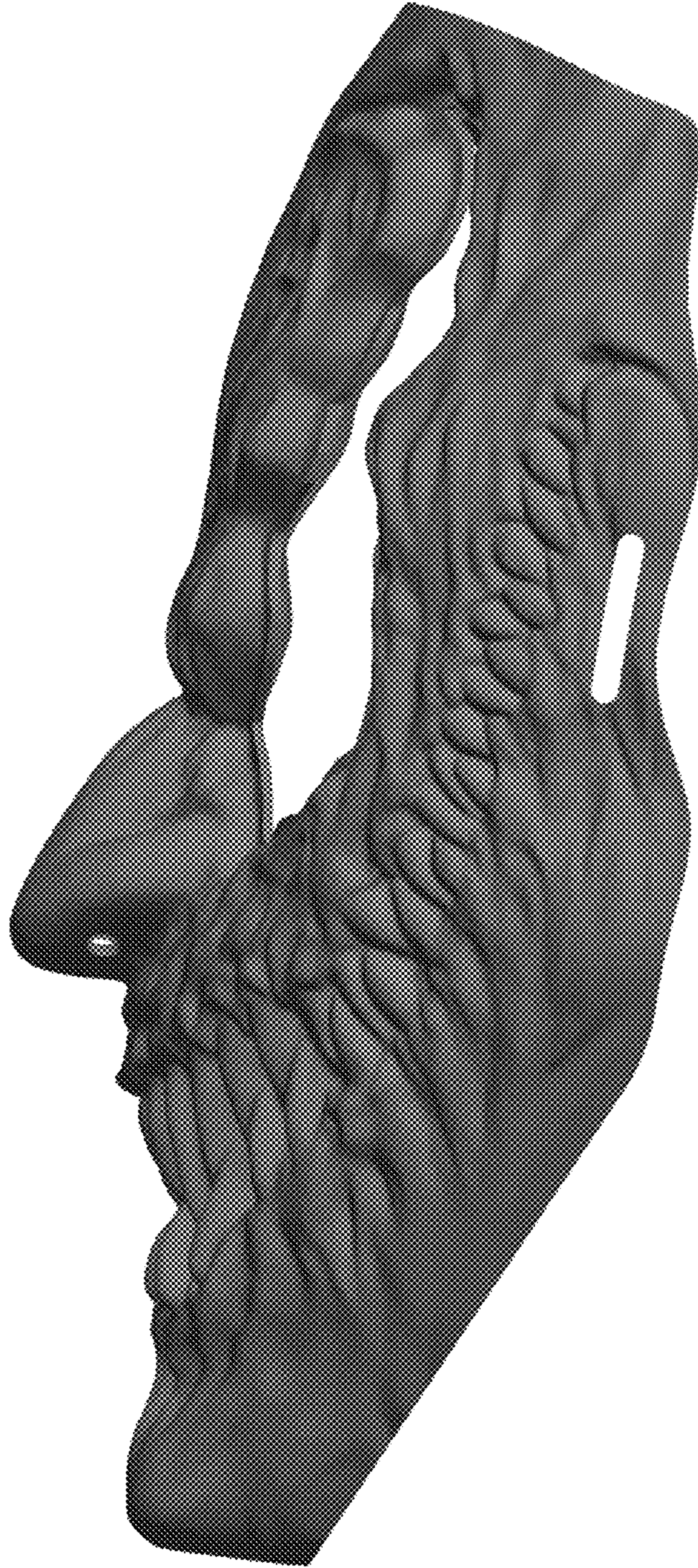


FIG. 5



FIG. 6

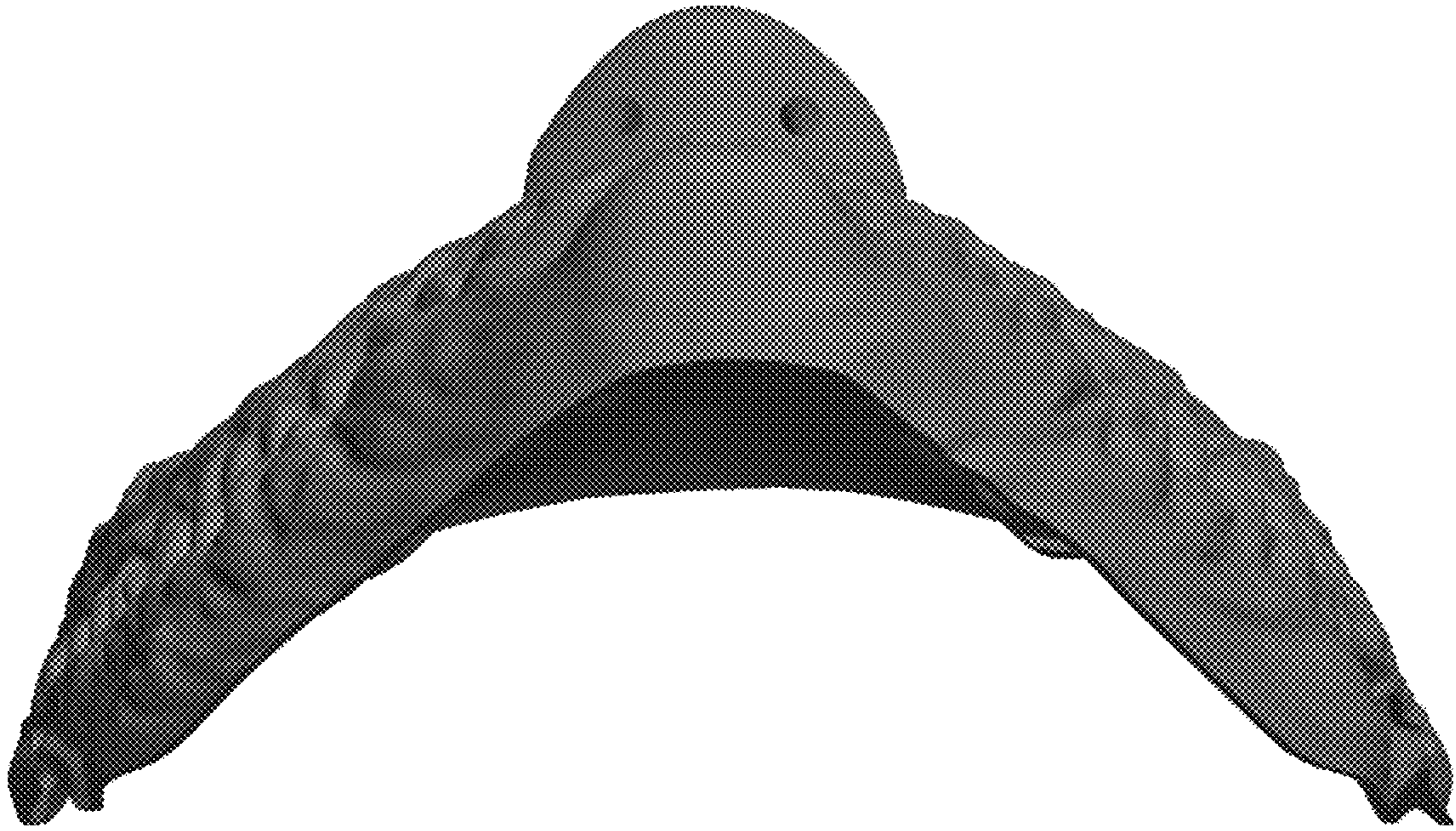


FIG. 7